



Light-matter interactions in aligned silver nanorod arrays

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ARTICLE INFO

Article history:

Received 14 January 2016

Received in revised form 13 August 2016

Accepted 18 August 2016

Available online 20 August 2016

Keywords:

Silver

Nanorods

Physical vapor deposition

Reflectance

Surface plasmon resonance

Oblique angle deposition

Glancing angle deposition

ABSTRACT

This study presents an experimental evaluation of the light-matter interactions in silver nanorod arrays of various lengths fabricated by electron-beam physical vapor deposition. The reflectance of nanorod arrays is found to decrease with increasing nanorod length, reaches to a minimum and then again increases with increasing length. Since nanorod arrays are subwavelength structures, the decrease in reflectance is primarily due to surface plasmon resonance. At the tip of the nanorods, the light excites the surface plasmons, which propagate along the conductor-dielectric interface. Hence, longer and consequently higher surface area nanorod arrays provide more dielectric-conductor interface for light to couple with the surface plasmons and more surface to scatter resulting in lower reflectance.

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1. Introduction

Physical vapor deposition (PVD) grown silver (Ag) nanorods have attracted significant attention recently in science and technological applications, including plasmonics [1,2], and sensors [3–6] through surface-enhanced Raman spectroscopy (SERS). Such nanorods have shown SERS enhancement factors of $\sim 10^9$ [7] and this enhancement strongly depends on the length of the nanorods [3], the incident angle [7], the polarization of excitation light [8], and the design of the structure [9].

Zhao et al. [7] extensively worked on PVD grown Ag nanorods and characterized the optical properties of nanorods grown at various deposition angles and lengths. They reported that SERS enhancement factor increases nearly monotonically with the decrease of the reflectance of Ag nanorods at the SERS excitation wavelength, and the reflectance depends on the length of the Ag nanorods as well as on the deposition angle. They also reported that Ag nanorods deposited with larger deposition angles provide lower reflectance. It is also reported that zig-zag structure of Ag nanorod arrays enhance SERS performance, possibly by creating hot spots for increased SERS at the bends [9]; but there is a lack in clear understanding of the mechanism behind the optical behavior of PVD grown Ag nanorods.

In this study, we report the optical reflectance of Ag nanorod arrays with varying length of nanorods at a fixed high deposition angle (86.5°). We also report, for the first time, optical properties of zig-zag structure

of Ag nanorod arrays. We found that long and high surface area nanorod arrays show lower reflectance, which may be attributed to the surface plasmon resonance.

2. Methods

Ag nanorods are fabricated by the oblique angle deposition using a custom designed high vacuum electron beam PVD. The source material is Ag pellets (99.99%, Kurt J. Lesker Co., Jefferson Hills, PA, USA) and is placed in a graphite liner at the base of the vacuum chamber. The vacuum chamber is approximately 45 cm tall and 25 cm in diameter. The Ag nanorods are grown on Si {100} substrates (Nova Electronic Materials, Flower Mound, TX, USA) with native oxide layer. First, Si substrates are ultrasonically cleaned using acetone, ethanol, and deionized water and then placed at the top of the chamber. A base layer of 500 nm Ag film is deposited at a low deposition rate of 0.5 nm/s to form a uniform thickness film. Then the substrates are oriented to an oblique angle of 86.5° using a custom designed precision mount. The source to substrate distance is approximately 30 cm. The Ag nanorods are grown to a thickness of 50, 100, 250, 500, 750, and 1000 nm at a deposition rate of 2 nm/s. The deposition is monitored by a quartz crystal microbalance (QCM) positioned perpendicular to the incoming flux. In each deposition, base pressure was around 6.7×10^{-4} Pa.

Immediately following the deposition, Ag nanorods are analyzed using scanning electron microscope (SEM) (FEI Quanta 250, FEI, Hillsboro, OR, USA) with an accelerating voltage of 10 kV, and energy dispersive X-ray spectroscopy (EDX) with an accelerating voltage of 20 kV. In order to identify crystallographic structure, Ag nanorods arrays are characterized by X-ray diffraction (XRD) using a Bruker D8 Advanced

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system with Cu K α radiation ($\lambda = 1.5406 \text{ \AA}$). A sample of Ag nanorod arrays on Si substrate with dimension $1.5 \text{ cm} \times 1.5 \text{ cm}$ is used for XRD analysis. The reflectance of the Ag nanorod arrays is measured using a UV-VIS 2600 spectrometer with an integrating sphere attachment (Shimadzu Corporation, Kyoto, Japan). Ag nanorods are fabricated in high vacuum condition and are stored in vacuum chamber between analyses, however nanorods are exposed to environment during sample preparation for SEM, and during UV-VIS measurements and a thin oxide layer may form at the surface.

To measure surface area of each nanorod arrays, high resolution images are analyzed. From multiple locations with area of $1 \mu\text{m}^2$ of high resolution images, average length and average diameter of the nanorods are measured and number density is counted manually. Although the nanorods are not entirely cylindrical and uniform or smooth, approximate total surface area in $1 \mu\text{m}^2$ base area is calculated assuming all the nanorods are cylindrical with the average measured diameter. The parameters of Ag nanorod arrays with the length of 50 and 1000 nm are not presented here because nanorods are too short to measure in 50 nm nanorod arrays, and nanorods are overlapped each other in 1000 nm nanorod arrays.

3. Results and discussion

Fig. 1 shows SEM images of the nanorod arrays fabricated at 86.5° with three different lengths. The nanorod arrays are grown due to so called geometric shadowing effect [10,11], and the actual lengths of the nanorods are larger than QCM measured values (Table 1). At smaller lengths, nominal diameters of the nanorods are small (Table 1) and they are well separated. With increasing length, nanorods start to overlap each other, resulting in a decreased number density and increased

Table 1
Parameters of Ag nanorod arrays.

Length of nanorod measured by QCM (nm)	Actual average nanorod length (nm)	Nanorod density (number/ μm^2)	Average nanorods diameter (nm)	Total surface area in $1 \mu\text{m}^2$
Base layer	–	–	–	$1 \mu\text{m}^2$
100	140 ± 20	100 ± 5	46 ± 20	$3.19 \mu\text{m}^2$
250	298 ± 20	47 ± 5	74 ± 20	$5.41 \mu\text{m}^2$
500	540 ± 20	32 ± 5	96 ± 20	$7.80 \mu\text{m}^2$
750	800 ± 20	13 ± 5	150 ± 20	$6.11 \mu\text{m}^2$

diameter of the nanorods. As the length of the nanorods increase, total surface area increases and reaches to a maximum as long as nanorods remain separated, and decreases when nanorods start to merge together (Fig. 2). Under the current deposition conditions, highest surface area is found for 500 nm length Ag nanorod array.

The nanorods are characterized using EDX and XRD to analyze the chemical compositions and crystallographic structure, respectively. Here, we present the results of Ag nanorod arrays with 500 nm as an example, however all samples show similar chemical composition and crystallographic structure. EDX (Fig. 3a) shows the presence of Ag on the Si wafer, and XRD pattern (Fig. 3b) shows the polycrystalline behavior of the Ag nanorod arrays. XRD pattern contains peaks at $2\theta = 38.11, 44.30, 64.45, 77.40, \text{ and } 81.54$ which are indexed as (111), (200), (220), (311), and (222) planes, respectively, which correspond to face-centered cubic Ag. The film has a higher intensity of (111) crystal orientation similar to what is reported by Khare et al. [12] and Oh et al. [13].

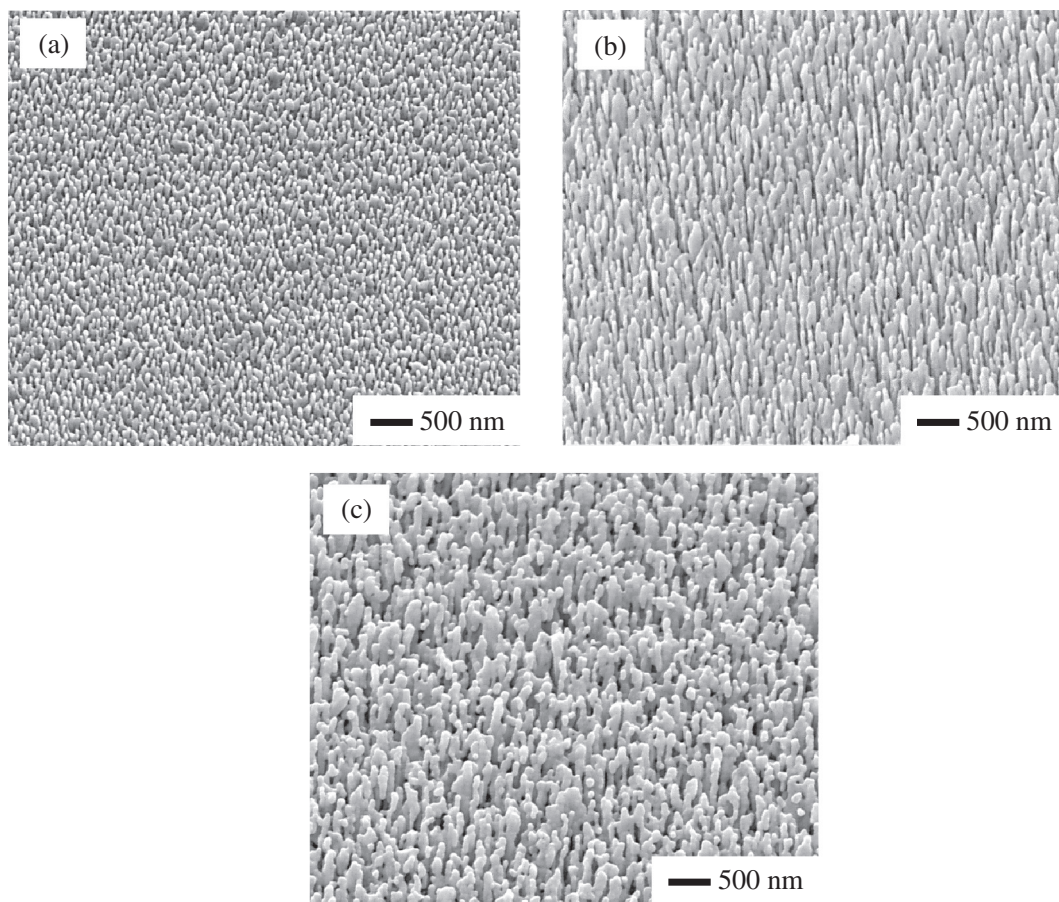


Fig. 1. Shape of nanorod arrays at different lengths. SEM images of Ag nanorod arrays with length (a) 100 nm, (b) 500 nm, and (c) 750 nm.

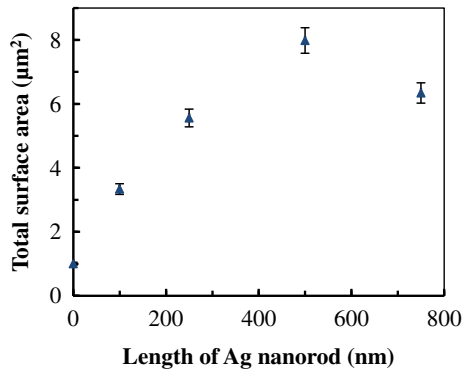


Fig. 2. Total surface area of different Ag nanorod arrays.

Fig. 4 shows the reflectance of the base Ag layer and Ag nanorod arrays of different lengths. There is no difference observed in the reflectance profile of 500 and 2000 nm thick base Ag films, therefore the reflectance measured on 500 nm Ag film shows the characteristics of Ag and, only reflectance of 500 nm Ag film is shown. In wavelengths >400 nm, average Ag reflectance is 96% which shows highly reflecting nature of Ag. At ~ 320 nm wavelength, there is a sharp drop in reflectance which is attributed to the interband absorption associated either

with transitions from Fermi level to the next higher empty band or with transitions from a lower lying filled band to the Fermi level [14]. There is also a drop in reflectance at 225 nm which can also be attributed to interband transition [14].

To eliminate the effect of substrate in the reflectance measurements, nanorod arrays are grown on 500 nm Ag film. Reflectance profiles show similar pattern for all nanorod arrays. There are drops in reflectance at 320 and 225 nm similar to Ag base layer. In wavelength >400 nm, reflectance decreases with an increase in the length of nanorods, reaches a minimum and then starts to increase. As shown in Fig. 5 for the wavelengths of 600 and 1200 nm, the minimum reflectance is found for 500 nm Ag nanorod arrays, which has the highest surface area. The change in the reflectance with the length of the Ag nanorods is proportional to the total surface area, and the high surface area nanorod arrays show lower reflectance.

Along with overall decrease in the reflectance, there are some other specific drops (valleys) at certain wavelength in the reflectance profile listed in Table 2. These drops and overall decrease in reflectance can be attributed to the surface plasmon (SP) resonance absorption [14], which is defined as a collective motion of electrons excited by the lights and travel along the dielectric/conductor interface and hence decrease reflectance [15]. The dimensions and gaps between Ag nanorods are well below the optical wavelength. In these subwavelength structures, light can couple to SPs at the nanorod tips and SPs propagate along

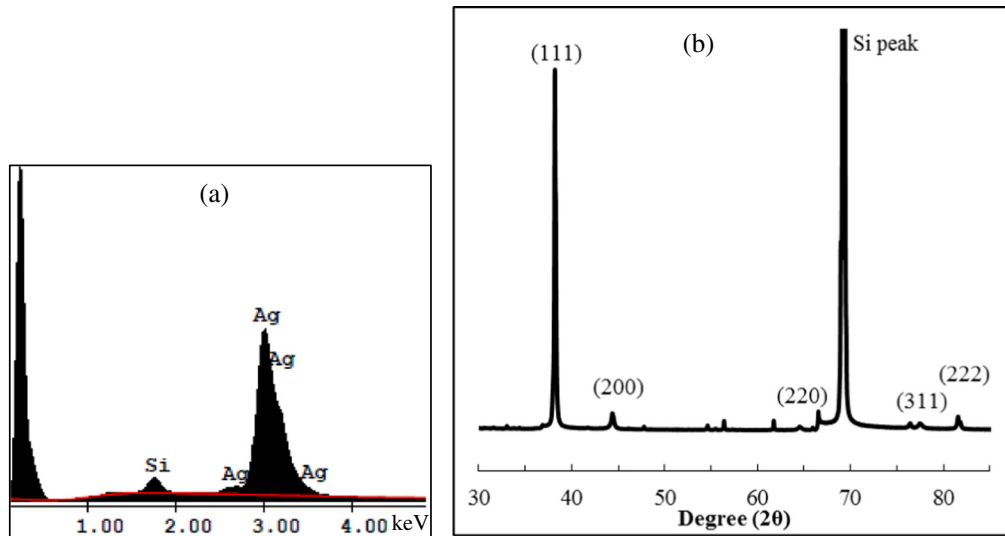


Fig. 3. (a) Energy dispersive X-ray spectroscopy (EDX) and (b) X-ray diffraction (XRD) pattern of Ag nanorod arrays (500 nm length) on silicon wafer.

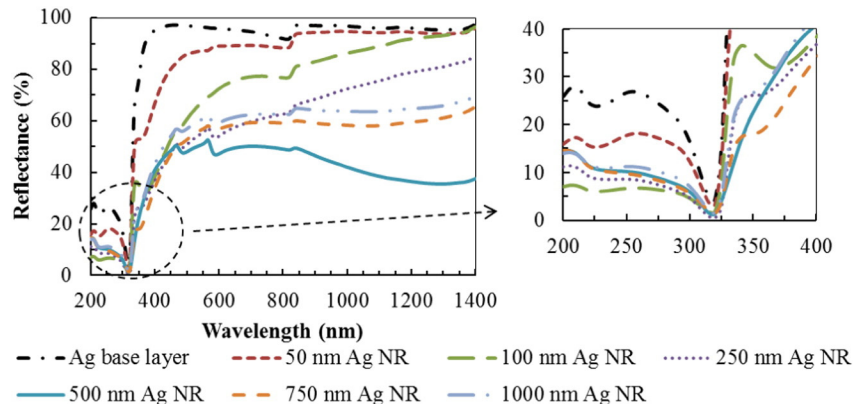


Fig. 4. Reflectance of Ag nanorod (NR) arrays with different lengths. All the nanorods are grown on 500 nm thick flat Ag base layer.

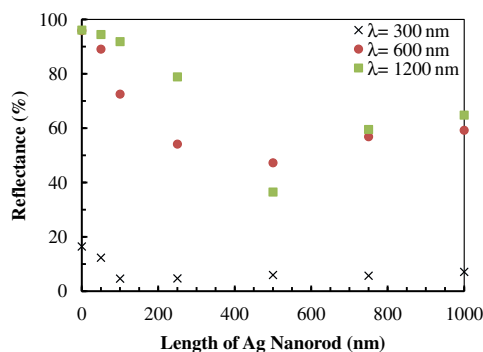


Fig. 5. Reflectance of Ag nanorod at different wavelengths (300 nm, 600 nm, and 1200 nm) as a function of nanorod length.

Table 2

Reflectance valley wavelength of Ag nanorod arrays.

Ag nanorod length (nm)	Reflectance valley wavelength (nm)
50	360
100	370, 480
250	355, 485, 585
500	490, 590
750	355, 485, 590
1000	355, 485, 590

the nanorods, allowing them to serve as optical waveguides [16]. Barbara et al. [16] reported that 760 to 860 nm wavelengths of light can travel 11 to 17.5 μm in Ag nanowire with a diameter of 80 nm. Light propagates along the nanorods (through SPs) and scatter inside the nano-structure and can be absorbed by neighboring nanorods. In nanorods arrays with high surface area, there is a larger surface area for light interaction with SPs and more light is absorbed resulting in lower reflectance.

Moreover, SP induced light absorption is believed to be enhanced by the nanoscale topologies, such as small gaps, corners, or bends, named hot spots [9]. In order to generate potential hot spots by bending nanorods, a zigzag Ag structure with small corners is fabricated. First, Ag nanorods are grown in one direction and the substrate is rotated 180°, and nanorods are grown again in the alternating direction, and zigzag structure is obtained by rotating the substrate 180° several times while depositing the nanorods. Fig. 6a shows the SEM image of zigzag structure with two foldings of the Ag nanorod. At each step before the rotation, the QCM measured length of the Ag nanorods was 250 nm. The reflectance is measured at each step and presented in Fig. 6b. With one folding, reflectance decreases compared to the one layer of Ag nanorod arrays showing confinement of light in the subwavelength structures. With two foldings, reflectance does not decrease further, but increases slightly due to decrease in overall porosity of the structure, consequently lower surface area.

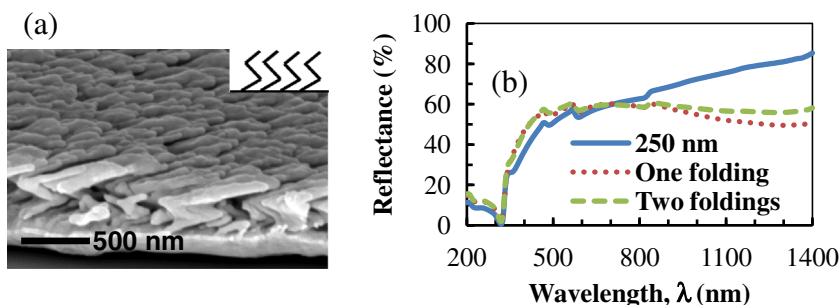


Fig. 6. (a) SEM image and (b) reflectance profile of zigzag Ag nanostructures.

It is necessary to mention here that optical properties of the aligned Ag nanorod arrays are anisotropic and they strongly depend on polarization of incident angle because when light hits aligned nanorods, the oscillation of the electric field induces the longitudinal plasmon mode along the nanorods and the transverse plasmon mode perpendicular to the nanorods [8,17]. Understanding the effect of the polarization of incident angle and individual components of surface plasmon resonance is part of our ongoing work.

4. Summary and conclusions

Silver nanorod arrays are fabricated by oblique angle deposition in an electron-beam physical vapor deposition at a constant deposition angle at different lengths. Shorter nanorods grow with small diameter and they are well separated. With the increase of the length, nanorod diameter increases and neighboring nanorods overlap each other, decreasing the overall surface area. Larger nanorods fuse together and are no longer separated. The reflectance of the nanorod arrays is lower compared to uniform Ag film, and reaches to a minimum for the nanorod arrays with highest surface area.

Characteristic dimensions of the nanorod arrays are well below the wavelength of the light. In these subwavelength structures, the decrease in reflectance can be attributed to the surface plasmon resonance. High surface area nanorod arrays provides higher dielectric-conductor interface for light-matter coupling resulting in lower reflectance.

Acknowledgement

The authors gratefully acknowledge financial support from the National Science Foundation (CBET-0748063). The authors also thank Dr. Stephen P Stagon for help with physical vapor deposition.

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